What is claimed is:

A thermally curable polymer composition comprising a hydroxyl-containing polymer, an amino cross-linking agent and a thermal acid generator, wherein said hydroxyl-containing polymer comprises monomer units selected from the group consisting of: cyclohexanol, hydroxystyrene, hydroxyalkyl acrylate or methacrylate, hydroxycycloalkyl acrylate or methacrylate, hydroxyalkylcycloalkyl acrylate or methacrylate, arylalkyl alcohol, and allyl alcohol.

- 2. The composition of claim 1 wherein said hydroxyl-containing polymer comprises monomer units of cyclohexanol, hydroxystyrene, hydroxyalkyl acrylate or methacrylate, biphenyl acrylate or methacrylate and hydroxycycloalkyl acrylate or methacrylate and has a number average molecular weight between about 14,000 to 30,000.
- 3. The composition of claim 1 wherein said thermal acid generator has the general structure:

$$\begin{array}{c|c}
R_{7}-O & R_{8} & R_{9} \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
& & \\
&$$

where R₇ is a substituted or unsubstituted alkyl, cycloalkyl or aromatic group wherein the substituted group is halogen, alkoxy, aromatic, nitro or amino group; and R₈ to R₁₂ are independently selected from hydrogen, linear or branched C₁ to C₄ alkyl, alkoxy, amino, alkylamino, aryl, alkenyl, halogen, acyloxy, cycloalkyl, or annulated cycloalkyl, aromatic or heterocyclic.

4. The composition of claim 1 wherein said amino cross-linking agent has the general formula:

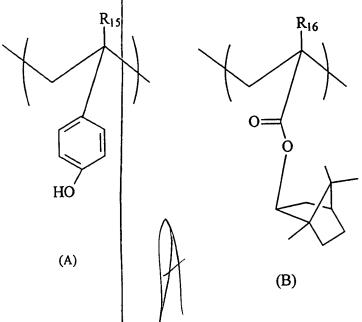
$$\begin{array}{c|c} R_1 & R_3 \\ R_2 & N & N \\ N & N \\ Y & \end{array}$$

wherein Y is NR₅R₆, or a substituted or unsubstituted aryl or alkyl group, R₁ to R₆ are independently a hydrogen or a group of the formula –CH₂OH or CH₂OR₁₇ where R₁₇ is a alkyl group of about 1 to 8 carbons.

- 5. The composition of claim 1 wherein said hydroxyl containing polymer comprises a monomer unit of allyl alcohol and has a polymer weight average molecular weight of 2000 to 20000.
- 6. The composition of claim 1 further comprising a monomer unit of a cycloaliphatic ester of acrylic or methacrylic acid.
- 7. The composition of claim 6 wherein said monomer unit of cycloaliphatic ester of acrylic or methacrylic acid is selected from the group consisting of cyclohexyl acrylate, cyclohexyl methacrylates, 4-tert-butylcyclohexyl acrylate, 4-tert-butylcyclohexyl methacrylate, isobornyl acrylate, isobornyl methacrylate adamantyl acrylates and methacrylates, dicyclopentenyl acrylates and methacrylates, 2-(dicylcopenteneyloxy)ethyl acrylates and methacrylates.
- 8. The composition of claim I wherein said hydroxyalkyl acrylate or methacrylate is selected from the group consisting of: hydroxymethyl acrylate or methacrylate, 2-hydroxyethyl acrylate or methacrylate, 3-hydroxypropyl acrylate or methacrylate, 4- hydroxybutyl acrylate or methacrylate, 5-hydroxypentyl acrylate or methacrylate and 6- hydroxyhexyl acrylate or methacrylate.

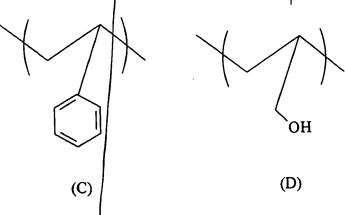
9. The composition of claim comprises the following monomer units:

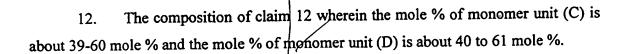
wherein said hydroxyl-containing polymer



wherein R₁₅ and R₁₆ are independently a hydrogen or a methyl.

- 10. The composition of claim 9 wherein the mole % of monomer unit (A) is about 25 to 60 mole % and the mole % of monomer unit (B) is about 40 to 75 mole %.
- 11. The composition of claim wherein said hydroxyl-containing polymer comprises the following monomer units:





- 13. The composition of claim by wherein said thermal acid generator is selected from the group consisting of: eyclohexyl p-toluenesulfonate, menthyl p-toluenesulfonate, bornyl p-toluenesulfonate, cyclohexyl triisopropylbenzenesulfonate, cyclohexyl 4-methoxybenzenesulfonate.
 - 14. A photolithographic sensitive coated substrate comprising:
- (a) a substrate;
- (b) a thermally cured undercoat on the substrate; and
- (c) a radiation-sensitive resist topcoat on the thermally cured undercoat; wherein said thermally cured undercoat comprises a thermally cured composition comprising a hydroxyl-containing polymer, an amino cross-linking agent and a thermal acid generator.
- The coated substrate of claim 14 wherein said hydroxyl-containing polymer comprises monomer units selected from the group consisting of: cyclohexanol, hydroxystyrene, hydroxyalkyl acrylate or methacrylate, hydroxycycloalkyl acrylate or methacrylate, aryalkyl alcohols, and allyl alcohol monomer units.
- 16. The coated substrate of claim 14 wherein said thermal acid generator has the general structure:

$$R_{7}-O-S = R_{10}$$
 R_{11}
 R_{12}
 R_{10}

where R₇ is a substituted or unsubstituted alkyl, cycloalkyl or aromatic group wherein the substituted group is halogen, alkoxy, aromatic, nitro or amino group; and R₈ to R₁₂ are

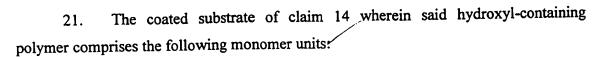
independently selected from hydrogen, linear or branched C₁ to C₄ alkyl, alkoxy, amino, alkylamino, aryl, alkenyl, halogen, acyloxy, cycloalkyl, or annulated cycloalkyl, aromatic or heterocyclic.

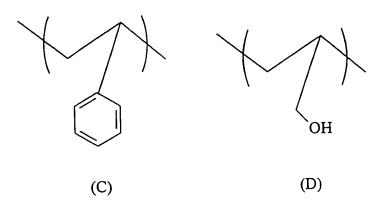
- 17. The coated substrate of claim 15 wherein said hydroxyl-containing polymer comprises monomer units selected from the group consisting of: hydroxyalkyl acrylate or methacrylate and allyl alcohol units.
- 18 The coated substrate of claim 14 wherein said hydroxyl-containing polymer further comprises monomer units of cycloaliphatic ester of acrylic or methacrylic acid units.
- 19. The coated substrate of claim 14 wherein said hydroxyl-containing polymer comprises the following monomer units:

$$R_{15}$$
 R_{16}
 R

wherein R_{15} and R_{16} are independently a hydrogen or a methyl.

20. The coated substrate of claim 19 wherein the mole % of monomer unit (A) is about 25 to 60 mole % and the mole % of monomer unit (B) is about 40 to 75 mole %.





- 22. The coated substrate of claim 21 wherein the mole % of monomer unit (C) is about 39-60 mole % and the mole % of monomer unit (D) is about 40 to 61 mole %.
- 23. The coated substrate of claim 14 wherein said hydroxyl-containing polymer comprises biphenyl acrylate or methacrylate and hydroxyethyl acrylate or methacrylate.
- 24. The coated substrate of claim 23 wherein the amount of biphenyl acrylate or methacrylate is about 50 to 90 mole % and the amount of hydroxyethyl acrylate or methacrylate is about 10 to 50 mole %.
- 25. The coated substrate of claim 14 wherein the radiation-sensitive resist topcoat is a chemically amplified resist containing silicon.
- 26. The coated substrate of claim 23 wherein the wherein the radiation sensitive topcoat comprises a polymer comprising the following monomer units:

wherein R_{13} is methyl or hydroxyethyl, R_{14} is hydrogen, methyl or $CH_2CO_2CH_3$, and R_{15} and R_{16} are hydrogen or methyl, with each choice made independently.

27. The coated substrate of claim 14 wherein said amino cross-linking agent has the general formula

$$\begin{array}{c|c} R_1 & R_3 \\ R_2 & N & N & R_4 \\ \hline & N & N & N \end{array}$$

wherein Y is NR_5R_6 , or a substituted or unsubstituted aryl or alkyl group, R_1 to R_6 are independently a hydrogen or a group of the formula $-CH_2OH$ or CH_2OR_{17} where R_{17} is a alkyl group of about 1 to 8 carbons.

A process for the production of relief structures comprising the steps of:

(a) forming a coated substrate; wherein said coated substrate comprises a substrate; a thermally cured undercoat disposed on said substrate; and a radiation-sensitive resist topcoat disposed on said thermally cured undercoat; and wherein said thermally cured

Who have the second of the sec

undercoat comprises a thermally cured composition comprising a hydroxyl-containing polymer, an amino cross-linking agent and a thermal acid generator;

- (b) imagewise exposing said radiation-sensitive resist topcoat to actinic radiation; and
- (c) forming a resist image by developing said radiation-sensitive resist topcoat with a developer.
- 29. The process of claim 26 wherein said hydroxyl-containing polymer comprises about 30 to 60 mole % of hydroxystyrene monomer units and 40 to 70 mole % of isobornyl acrylate or methacrylate monomer units.
- 30. The process of claim 26 wherein said hydroxyl-containing polymer comprises about 39 to 60 mole % of styrene monomer units and about 40 to 61 mole % of allyl alcohol monomer units.
- 31. The process of claim 26 wherein the amount of biphenyl acrylate or methacrylate is about 50 to 90 mole % and the amount of hydroxyethyl acrylate or methacrylate is about 10 to 50 mole %.
- 32. The process of claim 26 wherein said radiation sensitive resist topcoat comprises a polymer comprising the following monomer units:

wherein R₃ is methyl or hydroxyethyl, R₄ is hydrogen, methyl or CH₂CO₂CH₃ and R₅ and R₆ are hydrogen or methyl, with each choice made independently.



33. The process of claim 26 further comprising the step of: removing said thermally cured undercoat composition to form an image thereof.